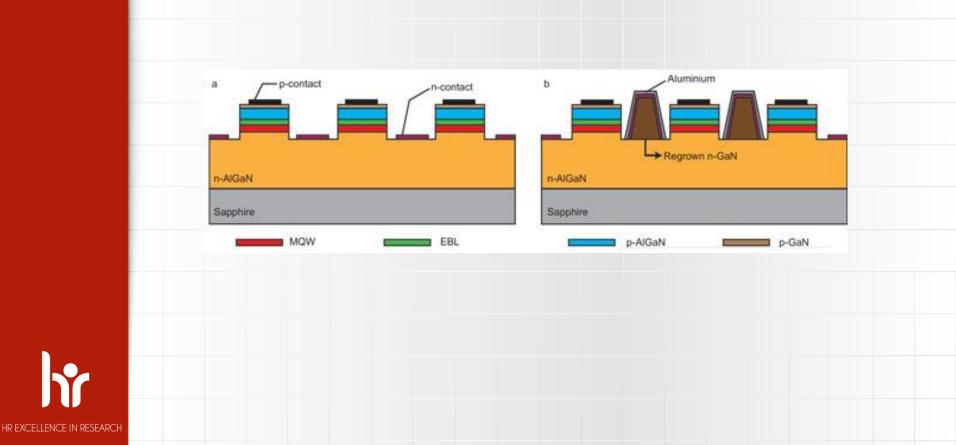


Wrocław University of Science and Technology

Advanced Optoelectronic

project





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p-contact

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Project

Oxide-confined layer

p-DBR

Output aperture

AR coating

.Passivation layer

ctive QWS

n-DBR

GaAs substrate

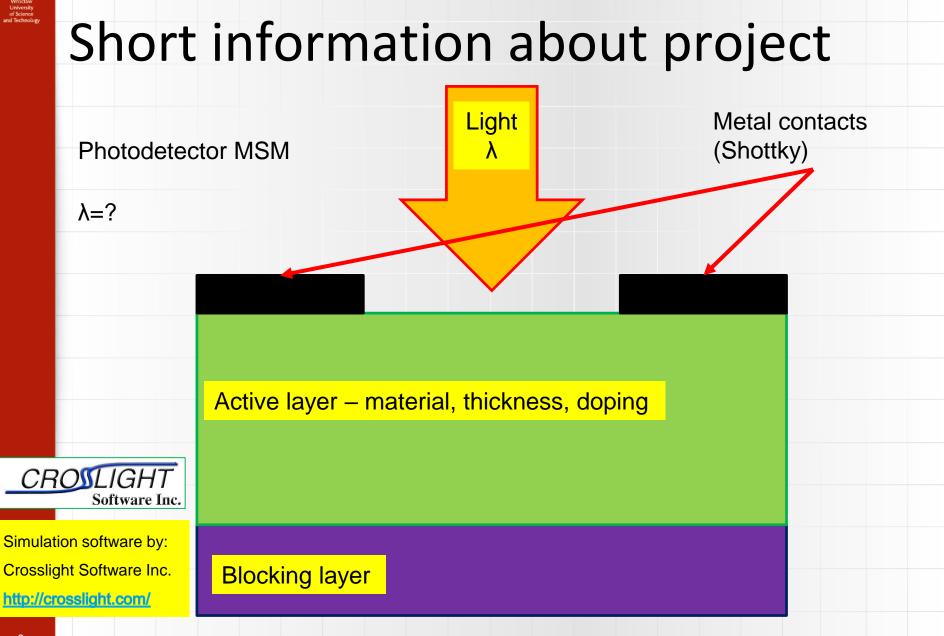
n-contact

Dr inż. Damian Radziewicz



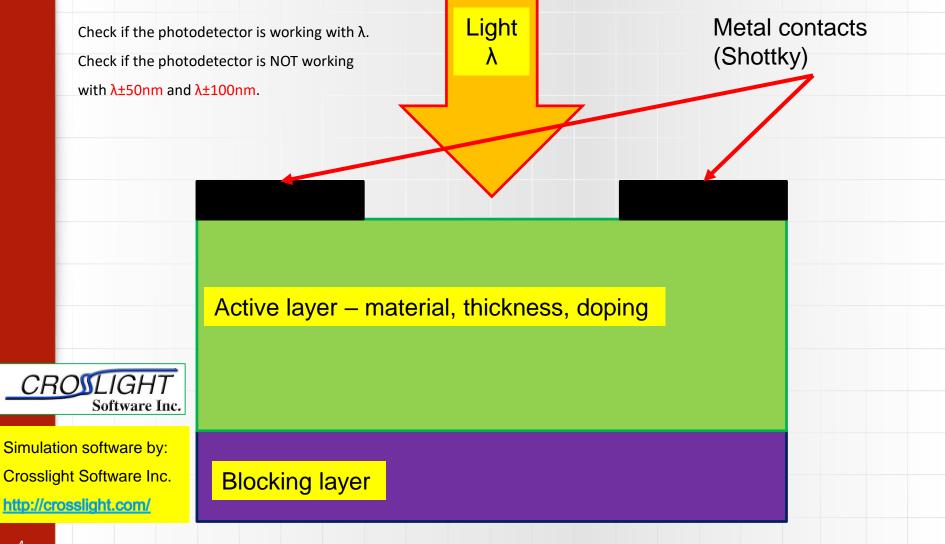
Wrocław 2017







Short information about project





End of Introduction